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Iron molybdate thin films prepared by sputtering and their electrochemical behavior in Li batteries

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Abstract

With the aim of developing 3V all-solid-state lithium microbatteries, $\text{Fe}_2(\text{MoO}_4)_3$ thin films were prepared by radiofrequency magnetron sputtering from a home-made $\text{Fe}_2(\text{MoO}_4)_3$ target using optimized sputtering conditions. In addition to elemental analyses, Mössbauer spectroscopy and XPS analyses, showing that Mo^{6+} and Fe^{3+} are the main detected species, confirmed the stoichiometric character of the films. Post-deposition annealing was necessary to form well-crystallized thin films. The best electrochemical performance was obtained with those annealed at 500°C which were able to deliver a stable reversible capacity close to the theoretical one, i.e. 2Li^+

per $\text{Fe}_2(\text{MoO}_4)_3$ formula unit. The corresponding voltage curve displays a plateau with a low hysteresis located at 3.0 V/ Li^+/Li and related to the $\text{Fe}_2(\text{MoO}_4)_3 - \text{Li}_2\text{Fe}_2(\text{MoO}_4)_3$ two-phase system. Therefore, it was demonstrated for the first time the possible use of $\text{Fe}_2(\text{MoO}_4)_3$ thin films as positive electrodes for 3 V lithium microbatteries.

Keywords: sputtering; lithium; iron molybdate; all-solid-state batteries

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1.Introduction

The significant growth of portable electronics, generally battery-powered has induced the development of high-performance microprocessors, and systems-on-a-chips using low power consumption integrated circuits. As a consequence, these optimized devices can be powered now by miniaturized power sources such as thin film all-solid-state lithium batteries. The latter have the advantage of being manufactured by vacuum deposition techniques that are widely used in the microelectronics industry. Up to now, the Li/LiPON/LiCoO₂ stack that supplies a 4 V voltage is the most widespread microbattery system [1]. Nevertheless, such an operating voltage is not the most suitable for many new emerging electronic devices, which often require significantly lower ones. Besides, the replacement of conventional Li/γ-MnO₂ primary batteries by thin film batteries in selected devices motivates the development of specific 3 V rechargeable systems [2]. Among the few possible positive thin film electrode materials able to reversibly insert/deinsert lithium around 3 V *vs* Li⁺/Li, iron molybdate appears as a suitable candidate since it combines the following features: the ability to reversibly insert/deinsert Li in bulk form due to a two dimensional open framework with low volumetric change, a quite low crystallization temperature, a low material cost and environmental friendliness. In addition, this option usefully allows to achieve a 3 V system by changing only one step in the manufacturing process of the standard LiCoO₂/LiPON/Li system, i.e. the one related to the positive electrode.

The metal molybdate family has been widely studied for photoluminescence, microwave, optical fibers, scintillator, moisture sensor and catalysis applications [3-7]. Among them, iron molybdate is largely used as a catalyst for selective oxidation of methanol to formaldehyde in industrial processes [8]. This material also exhibits interesting magnetic properties, i.e. ferromagnetic structure and dominant antiferromagnetic supersuperexchange coupling along the Fe-O-O-Fe paths [9] and the ability to reversibly insert lithium ions, reported for the first time by J. B. Goodenough in the bulk material [10].

The crystal structure of $\text{Fe}_2(\text{MoO}_4)_3$ is indexed in a monoclinic cell ($P2_1/a$ space group) at room temperature. It displays some similarities with the NASICON one and consists in corner sharing FeO_6 octahedra and MoO_4 tetrahedra, each oxygen atom being bound to one iron atom and one molybdenum atom [11]. Several synthesis methods were reported for the preparation of $\text{Fe}_2(\text{MoO}_4)_3$ including solid state reaction [12-13], co-precipitation [14-15], hydrothermal [16] and microwave synthesis [17].

Only few studies of the intercalation reactions in bulk $\text{Fe}_2(\text{MoO}_4)_3$ have been achieved so far. Both Delmas et al. [18] and Reiff et al. [19] have shown that lithium can be inserted electrochemically or chemically into the $\text{Fe}_2(\text{MoO}_4)_3$ framework. This induces the formation of a $\text{Li}_2\text{Fe}_2(\text{MoO}_4)_3$ compound having the same orthorhombic symmetry (space group $Pbcn$) than the high temperature $\text{Fe}_2(\text{MoO}_4)_3$ phase obtained above 518°C . During the galvanostatic reduction/oxidation (lithiation/delithiation) of the material, the voltage profile displays a well-defined plateau at 3 V vs Li^+/Li that reveals the course of a two-phase reaction. Due to its low theoretical capacities, 91 mAh.g^{-1} and 326 mAh.cm^{-3} , and its moderate operating voltage, $\text{Fe}_2(\text{MoO}_4)_3$ is not a suitable cathode for high energy lithium batteries. Besides, the capacity retention of the bulk material is quite limited since a fast decrease of the initial capacity over cycles is observed, even at a low current rate. This behavior has been attributed to a slow lithium insertion which originates from the nature of the two-phase reaction [18] and the poor electronic conductivity of the materials [20]. In order to overcome these limitations, the approach has consisted in shortening the ion diffusion length and electron transfer paths in the electrode by designing different nanostructures, in a similar way than for LiFePO_4 . Sun et al. have demonstrated the possibility to electrochemically insert Na ions in thin films synthesized by sputtering and to achieve a far better electrochemical performance compared to bulk material electrodes [21]: at a low current rate (0.1 C) the specific capacity for the powder was 83 mAh.g^{-1} and 25 mAh.g^{-1} , for the 1st and the 30th cycle respectively, whereas for the

thin film it reached 94 mAh.g⁻¹ and 76 mAh.g⁻¹, for the 1st and the 100th respectively. A similar improvement of the electrochemical behavior was observed for Fe₂(MoO₄)₃/nanosilver composite [22] and Fe₂(MoO₄)₃/reduced graphene oxide composite [23-24] during Na insertion/deinsertion. In the latter case, it was demonstrated for the first time the possibility to deliver a capacity of 68 mAh.g⁻¹ at 5C and to retain 56.5 mAh.g⁻¹ after 100 cycles. This excellent behavior was mainly attributed to a good conductivity of the composite electrode, high specific surface area (reduced particle size) and significantly enhanced diffusion coefficient. Now, to our knowledge, there is no report on the electrochemical behavior of Fe₂(MoO₄)₃ thin films towards Li insertion/deinsertion so far.

In the present study, radio-frequency sputtering, which is a versatile technique and a process widely used in the microelectronic industry, was used to prepare iron molybdate thin films from an in-house Fe₂(MoO₄)₃ target. Sputtering conditions especially the oxygen partial pressure and the total pressure were optimized to get stoichiometric Fe₂(MoO₄)₃ films. Then, thorough physico-chemical and electrochemical characterizations were performed on stoichiometric films annealed at various temperatures between 200 °C and 500 °C to optimize the electrochemical performance.

2. Material and methods

2.1. Preparation of a Fe₂(MoO₄)₃ sputtering target

Iron molybdate was prepared by solid state reaction of Fe₂O₃ (Sigma-Aldrich, 99.0 %) and MoO₃ (Sigma-Aldrich, 99.9 %) in the molar ratio 2:3. The reactants were ball-milled in an agate jar at first. The resulting mixture was then annealed at 750°C for 20 h. The synthesized powder was used to prepare 2” targets by spark plasma sintering (SPS) at 600°C, under a pressure of 25 MPa, using a graphite die (50.8 mm). A dense target (compactness ~ 91%) was obtained and was further annealed in air at 450°C for 5 h to remove graphite traces present on its outer surface.

2.2. Thin films synthesis by sputtering

All thin films were deposited by radio-frequency (RF) magnetron sputtering (PLASSYS MP450) at room temperature with no intentional heating of the substrates. Before deposition, vacuum was applied into the chamber until the pressure is less than $4 \cdot 10^{-5}$ Pa. Prior to each deposition, pre-sputtering was systematically carried out for 1h in order to clean the target surface. The distance between the target and the substrate was fixed at 8 cm. Sputtering was performed in a pure argon or a mixed argon/oxygen plasma having an oxygen concentration varying from 0 to 15 %. The total pressure was set at different values between 0.5 Pa and 8 Pa and the power was fixed to 60 W which corresponds to a power density of $3 \text{ W} \cdot \text{cm}^{-2}$. Deposition time was adjusted so that the thickness of the films was close to 500 nm, with an exception for samples dedicated to Rutherford Backscattering Spectroscopy (RBS) characterization for which the thickness was limited to 100 nm. Film thickness was measured using a stylus profilometer (Veeco-Dektak 6 M). Several substrates were used depending on the characterization method: stainless steel and Pt (diameter 14 mm), for XRD analysis, EPMA (Electron Probe X-ray MicroAnalyzer), X-ray photoelectron spectroscopy and electrochemical measurements, silicon wafer for RBS measurements and pure aluminum (99.999 %) for Mössbauer spectroscopy experiments. Sputtered thin films were annealed in air for 2 h at various temperatures between 200°C and 500°C after deposition.

2.3. Characterization of thin films

Elemental analyses were performed using an Electron Probe X-ray Micro Analyzer (EPMA) equipped with a CAMECA SX 100 Bruker. RBS experiments were carried out on 100 nm thick films by using a 2-MeV He ion beam at a backscattering angle of 150° using a silicon particle detector [25]. The composition and thickness of the thin films were determined by processing RBS

raw data with the SIMNRA software [26]. Experimental errors of RBS are close to 3% for Fe and Mo elements and 10% for oxygen content.

X-ray diffraction (XRD) was carried out using a PANalytical X'Pert with CuK α radiation ($\lambda = 1.5418 \text{ \AA}$). In-situ temperature X-ray diffraction (XRD) patterns were collected on a X'pert Pro PANalytical Bragg-Brentano θ - θ geometry diffractometer equipped with a X'Celerator detector and an Anton-Paar HTK1200 temperature chamber. The thin film deposited on Pt foil was heated at a $2^\circ\text{C}/\text{min}$ rate from room temperature to 550°C . Before each measurement, the temperature was maintained for 15 min to ensure its stabilization.

Raman scattering measurements were performed with a Horiba Jobin Yvon Labram HR-800 microspectrometer. Spectra were recorded using a 514.5 nm excitation wavelength of an Ar⁺ laser, with a power adjusted to 100 μW to avoid any degradation of the sample. No specific sample preparation was needed.

The cross-section and surface morphology of the thin films were investigated by scanning electron microscopy using a Jeol 6700-F microscope. To avoid a possible charging effect induced by the electron beam on the samples, the films were systematically coated with a thin gold film before observations.

X-ray photoelectron spectroscopy (XPS) was used to investigate the local structure of the thin films. XPS analyses were carried out with a Thermo Scientific K-Alpha X-ray photoelectron spectrometer using a focused and monochromatized Al K α radiation (1486.7 eV) (diameter of the irradiated area = 400 μm) under a residual pressure of 8×10^{-7} Pa on thin films deposited on a stainless steel or Pt

substrate. The spectrometer was calibrated using the photoemission lines of gold (Au 4f_{7/2} = 3.9 eV, with reference to the Fermi level) and copper (Cu 2p_{3/2} = 932.5 eV). The Au 4f_{7/2} full width at a half maximum (FWHM) was 0.5 eV. In this work, the peaks were recorded with constant pass energy of 20 eV. All samples were fixed on sample holders in a glove box directly connected to the introduction chamber of the spectrometer. The XPS analyses were carried out on powder Fe₂(MoO₄)₃, as-deposited and annealed thin films. Peaks were then shifted to align hydrocarbon C1s photoemission to 285.0 eV binding energy. Experimental curves were fitted with a combination of Gaussian (70%) and Lorentzian (30%) functions using a minimum number of components.

⁵⁷Fe Transmission Mössbauer spectra were measured with a 925 MBq source of ⁵⁷Co in rhodium metal. During the measurements, both the source and the absorber were kept at ambient temperature (21°C). The spectrometer was operated in the constant acceleration mode with a triangular velocity waveform. The velocity scale was calibrated with a high-purity α -Fe foil at room temperature. The total thickness of the analyzed thin film sample is 2 μ m (with a stack of four films). The spectra were fitted to appropriate combinations of Lorentzian profiles (quadrupole doublets) by least-squares methods. In this way, spectral parameters such as the quadrupole splitting (QS), the isomer shift (IS) and the relative resonance areas (A) of the different spectral components were determined. Isomer shifts are given relative to α -Fe.

Lithium coin cells (2032) were assembled in an argon-filled glovebox. A lithium foil (Chemetall, battery grade) was used as the negative electrode. The separator was a bilayer composed of a polypropylene non-woven fabric (Viledon, Freudenberg) and a polypropylene microporous membrane (Celgard 2400). The electrolyte was 1M LiPF₆ in a 1:1 volumetric mixture of ethylene carbonate (EC) and dimethyl carbonate (DMC) (UBE Europe GmbH). The charge/discharge cycles

were performed with a VMP3 potentiostat/galvanostat (Bio-Logic SAS) at 25°C at a constant current density between 2.3 and 3.5 V/Li⁺/Li.

3. Results and discussion

3.1. Composition

In a first attempt, the influence of two sputtering parameters, namely the oxygen concentration in the discharge gas and the total pressure, on the Fe/Mo ratio of the film was thoroughly studied. Series of samples were prepared by changing a single sputtering parameter at a time while keeping the others fixed. Then, depending on the film thickness, the Fe/Mo ratio in the films was determined by combining RBS and EPMA analyses. The results gathered in table 1 show at first that an increase of the oxygen concentration in the discharge gas induces a continuous decrease of both the Fe/Mo ratio and the deposition rate, the initial Fe/Mo ratio being close to 0.7 in absence of oxygen in the plasma and reaching 0.55 for an oxygen concentration of 15%. Besides, the raising of the total pressure from 0.5 to 8 Pa also leads to a decrease of the Fe/Mo ratio (table 1). The latter tendency is the outcome of two simultaneous phenomena having opposite influence on the deposition rate: in the chamber, (i) the presence of a larger amount of species in the gaseous phase favors the sputtering process, (ii) in the same time sputtered particles undergo more collisions with the gas species since the mean free path shortens, as a consequence sputtered atoms are more likely to be scattered and do not to reach the substrate. The deposition rate being divided at least by 3 when the total pressure is raised from 0.5 to 8 Pa (for an oxygen concentration fixed to 5 %), the second phenomenon is therefore predominant. As the scattering of sputtered atoms is more pronounced for lighter elements (Fe), a decrease of the Fe/Mo ratio in the film is also observed. A similar trend is evidenced when the oxygen concentration is raised from 0 to 15 %. In this case, the deposition rate is almost divided by 3. Finally, the targeted Fe/Mo ratio is achieved for the following optimized set of parameters: 60 W (3 W.cm⁻²), 2 Pa, 5 % O₂. Indeed, RBS and EPMA

experiments show that the actual Fe/Mo ratio of thin films prepared in these sputtering conditions is 0.66 ± 0.02 , i.e. the one for stoichiometric $\text{Fe}_2(\text{MoO}_4)_3$. Further annealing of the films does not modify the Fe/Mo ratio when the temperature is kept below 500 °C.

Surface chemical composition of the different iron molybdate samples (powder, as-deposited and annealed thin films) was also studied by means of XPS. The Fe2p core peaks of the $\text{Fe}_2(\text{MoO}_4)_3$ powder and thin films before and after annealing are respectively displayed in figures 1a, 1b and 1c. Table 2 gathers all the XPS data together associated with the samples analysed. Given the spin-orbit coupling, the Fe 2p core peak is split into two components Fe 2p_{3/2} and Fe 2p_{1/2} with an area ratio of 2/1. The Fe2p core peak has a complex character especially when Fe²⁺ and Fe³⁺ ions are simultaneously present in one compound. Indeed, the small chemical shifts corresponding to the main 3/2 and 1/2 components and additional secondary structures for each oxidation states are observed. These structures correspond to spin multiplet effects leading to peak asymmetry with a broadening towards high binding energies. More, satellite peaks (shake-up type) are associated to Fe²⁺ and Fe³⁺ ions.

Reference compounds such as metallic iron (Fe⁰), Fe₂O₃ (Fe³⁺), LiFePO₄ (Fe²⁺) and Fe₃O₄ (Fe³⁺/Fe²⁺) were analysed first. Fitting parameters such as the FWHM (full width at half maximum) of the satellite peaks, binding energy differences between main and corresponding satellite peaks ($\Delta E_{\text{main-sat peak}}$) as well as the peaks intensity ratios for Fe³⁺ and Fe²⁺ ions ($I_{\text{main peak}} / I_{\text{sat peak}}$) were therefore determined and used to fit $\text{Fe}_2(\text{MoO}_4)_3$ data. All the results summarized in table 2 are in agreement with the values reported in literature [27-30].

The XPS data of the three analysed samples are given in table 3 (note that for a relevant presentation of the table, we choose to report only Fe2p, Mo3d and O1s (relative to the materials) which explain why the total atomic % for each sample is not 100%. Indeed, C1s (CH_x, C-O and C=O contributions) and O1s (mainly O-C and O=C) should be added for an exhaustive

presentation, but we can consider that these informations are not essential for this paper. The decomposition of the Fe2p core peaks shown in figure 1 leads to an average oxidation number of 2.8 for the powder and the annealed thin film, and 2.9 for the as-deposited one. Therefore, this confirms that the majority of iron is present as Fe³⁺ in all samples in agreement with Mössbauer measurements exhibiting only the presence of Fe³⁺ (figure 2). The unexpected presence of Fe²⁺ ions is probably related to oxygen deficiency at the very surface of the samples. This point is strengthened by the fact that XPS analyses performed on samples (as deposited and annealed thin films) mechanically etched in ultra-high vacuum reveal a significantly lower contribution of Fe²⁺ species below the pristine surface.

It is worth noting that the Fe2p core peak becomes more defined and displays lower width for the annealed Fe₂(MoO₄)₃ film compared to the as-deposited one, consistently with the enhanced crystallinity obtained after annealing. The same trend is observed if we compare the as-deposited thin film with the powder.

The Mo 3d spectra shown in figure 1d, 1e and 1f, are split in two components, Mo 3d_{5/2} and Mo 3d_{3/2} with an area ratio of 3/2. The Mo 3d_{5/2} component located at 232.4 eV is attributed to Mo⁶⁺, which corresponds to the theoretical oxidation state of molybdenum in Fe₂(MoO₄)₃. The same evolution regarding crystallinity is observed for Mo3d core peaks which display lower full width at half maximum (FWHM) for the thin films compared to the powder and for the annealed thin film compared to as-deposited one.

The estimated Fe/Mo atomic percentage from XPS analyses for the powder, the as-deposited and the annealed thin films is 0.61, 0.59 and 0.67 respectively, which proves that the stoichiometry for the annealed thin film sample is close to the theoretical one.

Mössbauer spectra of the starting Fe₂(MoO₄)₃ powder and the thin film annealed at 500°C are both typical of a high-spin ferric ions (figure 2). The amount of Fe²⁺, if any, is less than the detection limit namely 1-2%. Spectra were fitted with a singlet of Lorentzian of width Γ close to 0.30 mm.s⁻¹

which a quadrupole splitting Δ close to 0.20 mm.s^{-1} . The isomer shift δ at 293 K is close to 0.40 mm.s^{-1} . The room temperature parameters (table 4) are very similar to those reported previously in literature [31]. The rather small quadrupole splitting value is indicative of only minor distortions of the (FeO_6) octahedra.

Finally, RBS, EPMA, Mössbauer and XPS analyses confirm that the targeted $\text{Fe}_2(\text{MoO}_4)_3$ composition was achieved by properly tuning the total pressure and the oxygen concentration in the chamber during the preparation of thin films by sputtering.

3.2. Structure and morphology

As-deposited thin films are poorly crystallized as shown by XRD pattern (figure 3a). They start to crystallize at about 340°C . After a thermal treatment at 500°C , the resulting diffraction pattern is characteristic of a monoclinic cell (space group $\text{P2}_1/\text{a}$) and does not show any additional peak that could be attributed to a secondary phase. It is clearly similar to the one obtained for the powder used to prepare the target (figure 3b). The refined cell parameters obtained by the full profile matching refinement (Rietveld method) for the powder are: $a = 15.736(5) \text{ \AA}$, $b = 9.246(2) \text{ \AA}$, $c = 18.265(5) \text{ \AA}$, $\beta = 125.32(2)^\circ$ with a $\chi^2 = 2.99$, in agreement with the values reported in the literature [32].

Raman spectra of thin films, as-deposited and after annealing at 500°C , are shown on figure 4. The spectrum of the powder used to prepare the target is also included as a reference. It exhibits well-defined bands, the major ones at ca. 355 , 785 , 936 and 970 cm^{-1} being typical of Fe-O, Mo-O-Mo and Mo=O vibrations in $\text{Fe}_2(\text{MoO}_4)_3$; the other ones visible at 993 and 824 cm^{-1} being assigned to stretching modes in MoO_3 [33-34]. The spectrum of the as-deposited thin film displays bands at similar wavenumbers, but having a large width that is typical of a poorly crystallized material. After

annealing at 500°C, the spectrum becomes close to the one of the powder, and evidences the achievement of a well-crystallized Fe₂(MoO₄)₃ thin film.

As highlighted by the presence of sharp peaks on the XRD patterns and Raman spectra, an annealing step is required to get well-crystallized thin films.

Scanning electron microscopy (SEM) images of the surface and the cross-section of the as-deposited thin film and of the one annealed at 500°C are shown on figure 5. The surface of the as-deposited film (figure 5a) appears very homogeneous and made of very small grains (around 10 nm size). The thermal treatment does not induce a marked change of the thin film morphology, but only a slight increase of the apparent grain size (20-30 nm). The cross section of the as-deposited sample (figure 5c) reveals the dense character of the film and a typical columnar growth, the column width being consistent with the apparent size of the grain present at the surface and being quite constant from the bottom to the top. Once annealed at 500°C, the only apparent change of the film morphology is a homogenous widening of the columnar grains up to 30 nm in diameter (figure 5d). The dense character of the films, both prior and after annealing, and the smooth character of their outer surface are real assets for the integration of these films in all-solid-state microbatteries since they will allow to get good contact between the electrode and the solid electrolyte (LiPON) deposited by sputtering at the top of the latter. Nevertheless, at this stage of the study, these morphological characters are expected to be rather detrimental to the electrochemical performance of the electrode since such a morphology prevents the liquid electrolyte to penetrate the film and to boost the ionic transport inside the electrode. In any case, the slight variation of the film morphology observed after the thermal treatment is not expected to play an important role on the electrochemical response of the material.

3.4. Electrochemical characterization

The electrochemical characterization of 500 nm thick $\text{Fe}_2(\text{MoO}_4)_3$ films deposited with optimized conditions (60 W, 2 Pa, 5 % O_2) was performed in coin cells using a Li metal negative electrode and a liquid electrolyte. The charge/discharge cycles were performed at a constant current density between 2.3 and 3.5 V/ Li^+/Li , the lower cut-off voltage was chosen to avoid the reduction of Mo^{6+} into Mo^{4+} that would induce an irreversible modification of the initial structure [10].

First galvanostatic cycles for as-deposited samples and films annealed at 200, 300, 400 or 500 °C displayed on figure 6a, show that almost 2 Li^+ ions per $\text{Fe}_2(\text{MoO}_4)_3$ can be inserted in the thin film material during the first discharge whatever the annealing temperature. Nevertheless, in absence of thermal treatment or after a moderate annealing (temperature not higher than 300 °C), the films display a poor electrochemical performance (figure 3a) that is related to their low crystallinity. Thus, the voltage curves of these samples do not exhibit any marked plateau and a large part of Li^+ ions cannot be removed during the first charge. It has to be noted that the open circuit voltage for the as-deposited thin film is slightly higher than the one for annealed films (3.7 V instead 3.2 V/ Li^+/Li). Finally, only 0.9, 0.3 and 0.4 Li^+ ions per formula unit can be respectively de-inserted from the as-deposited sample and thin films annealed at 200 or 300°C. On subsequent cycles, the discharge capacity value stabilizes at a value corresponding to less than 30 % of the theoretical capacity (figure 6b). On the contrary, after a thermal treatment at 400 and 500°C, the discharge and charge curves display a very flat plateau at about 3 V and a very low polarization (~50/2 mV) (figure 6a and 6c). The flatness of the open circuit voltage curve is consistent with a two phase reaction $\text{Fe}_2(\text{MoO}_4)_3 + 2 \text{Li}^+ + 2 \text{e}^- \rightleftharpoons \text{Li}_2\text{Fe}_2(\text{MoO}_4)_3$ reported in the literature [10]. During the first discharge, about 2 Li^+ ions are inserted per formula unit corresponding to the formation of the $\text{Li}_2\text{Fe}_2(\text{MoO}_4)_3$ phase and the reduction of Fe^{3+} ions into Fe^{2+} ones (confirmed by *ex situ* Mössbauer analyses not shown here). Despite the fact that the shape of the voltage curves is the same for thin film electrodes annealed at 400°C and 500°C, the sample annealed at a higher temperature exhibits a significantly lower capacity loss at the first cycle and a better capacity retention during subsequent

cycles, retaining around 90% of the initial capacity after 20 cycles (figure 6b). Therefore, a well-crystalline film is mandatory to get the best electrochemical performance.

The first sweep voltammetry cycle (figure 6d) for the thin film annealed at 500°C displays one asymmetric peak in reduction with a maximum at 2.92 V and a sharper peak in oxidation at 3.05 V. Surprisingly, during the second cycle, the peak in reduction is clearly made of components at 2.967 V and 2.923 V, while the shape of the subsequent oxidation peak remain quite unchanged. This tendency was observed systematically on different samples. Due to the tiny potential difference between the two peaks, this phenomenon cannot be observed on the galvanostatic curve, but is visible on the derivative plots of the capacity vs potential curves for electrodes cycled at constant current. Such a two-step behavior, but with a larger gap between the two reduction peaks, was observed on voltametric curves during Na insertion [21]. This behavior is likely to be related to the generation of a compressive stress in the film, parallel to the substrate, induced by the swelling of the material during its lithiation (+6 vol.%), and which would be absent or delayed in a part of the electrode material after the first swelling-shrinkage cycle. Indeed, it is well-known that the stress caused by the volume expansion of electrode materials during its lithiation can modify both their open circuit voltage at equilibrium and their reaction over-potential at non-equilibrium [35].

Finally, the influence of the current rate on the capacity retention of the thin film electrode annealed at 500°C (figure 7) was studied. As already mentioned, the volumetric capacity is higher than 30 $\mu\text{Ah}\cdot\text{cm}^{-2}\cdot\mu\text{m}^{-1}$ for the first cycle achieved at C/20 (figure 7a), which is very close to the theoretical specific capacity for this material (33 $\mu\text{Ah}\cdot\text{cm}^{-2}\cdot\mu\text{m}^{-1}$). This capacity remains quite stable around 27 $\mu\text{Ah}\cdot\text{cm}^{-2}\cdot\mu\text{m}^{-1}$ during 30 cycles. When the current density is significantly increased (C rate), the delivered capacity is drastically reduced to 32 % of the initial value, while remaining stable over several hundreds of cycles. Subsequently, when cycling at a C/20 rate is resumed, it appears that the

capacity drop is fully reversible, hence that the latter originates from a limitation on the motion of either Li^+ or e^- in the film. The voltage curves measured at C/20 and C rates (figure 7b) indicate a slight increase of the polarization (30 to 90 mV) on the plateau, but a large increase of the concentration polarization near the end of charge/discharge responsible for the limitation of the amount of Li^+ that can be inserted/extracted at high rate. The low kinetics of the electrode reaction is probably favored by the two-phase mechanism that contributes to maintain the electronic conductivity of the electrode material at a low level during the course of the electrochemical reaction (absence of a mixed valence cations) [20]. The two-phase transformation at room temperature from monoclinic $\text{Fe}_2(\text{MoO}_4)_3$ to orthorhombic $\text{Li}_2\text{Fe}_2(\text{MoO}_4)_3$ is not likely to favor the kinetics of lithium intercalation because:

- (i) the phase separation of $\text{Fe}_2(\text{MoO}_4)_3$ containing only Fe^{3+} species and $\text{Li}_2\text{Fe}_2(\text{MoO}_4)_3$ containing only Fe^{2+} does not favor a facile electronic transport through the film (absence of solid solution and single-phased material containing both Fe^{3+} and Fe^{2+} ;
- (ii) the phase boundary is generally an obstacle to the Li^+ diffusion [36].

Conclusion

Iron molybdate $\text{Fe}_2(\text{MoO}_4)_3$ thin films were prepared by radio-frequency sputtering from a home-made target using adequate oxygen concentration and total pressure in order to get the stoichiometric composition, which was checked by RBS and EPMA analyses. Results from Mössbauer and XPS experiments, showing that Mo^{6+} and Fe^{3+} are the main detected species, were also consistent with the achievement of a $\text{Fe}_2(\text{MoO}_4)_3$ composition. Post-deposition annealing was necessary to get well-crystallized thin films displaying good electrochemical performances. Therefore, it was demonstrated for the first time the possible use of this material as a positive electrode in lithium thin film batteries. Best capacity value and capacity retention were obtained for

thin films annealed at 500°C, cycled between 2.3 V and 3.5 V vs Li⁺/Li at a C/20 regime in liquid electrolyte cells.

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Table captions

Table 1 : Fe/Mo ratio and deposition rate for iron molybdate thin films prepared at various total pressures and oxygen concentrations in the discharge gas.

Table 2: Fe2p core peaks deconvolution parameters

Table 3: XPS data (Fe2p, Mo3d, O1s) and surface composition of $\text{Fe}_2(\text{MoO}_4)_3$ powder and thin films prior and after annealing at 500°C.

Table 4: Mössbauer parameters of $\text{Fe}_2(\text{MoO}_4)_3$ powder and thin film at room temperature

Total pressure (Pa)	Oxygen concentration (%)	Fe/Mo ratio	Deposition rate (nm.h ⁻¹)
0.5	5	0.74 ± 0.02	170
2	5	0.66 ± 0.02	130
8	5	0.63 ± 0.02	50
2	0	0.72 ± 0.02	250
2	10	0.60 ± 0.02	95
2	15	0.55 ± 0.02	90

Table 1

Iron oxidation states	Fe ⁰	Fe ²⁺	Fe ³⁺
B.E. of the main peak 2p _{3/2} (± 0.2 eV)	706.7	709.6	711.7
Δ main 3/2 peak-sat 3/2 peak (eV)	-	5.8	8.7
I (main 3/2 peak) / I (sat.3/2 peak)	-	0.4	0.075
satellite peaks FWHM (± 0.2 eV)	-	4.2	2.9

Table 2

	Powder		As-dep. thin film		Thin film annealed at (500°C)		
	BE(eV) (FWHM)	Atomic %	BE(eV) (FWHM)	Atomic %	BE(eV) (FWHM)	Atomic %	
Fe 2p	709.6 (1.7)	0.8	709.6 (1.7)	0.3	709.4 (1.8)	0.5	Fe²⁺ Main peak
	711.9 (--)	3.8	711.7 (--)	5.5	711.7 (--)	5.7	Fe³⁺ Main component
	715.3 (4.2)	0.3	715.3 (4.2)	0.1	715.1 (4.2)	0.2	Fe²⁺ Sat. peak
	720.6 (2.9)	0.3	720.4 (2.9)	0.4	720.4 (2.9)	0.4	Fe³⁺ Sat peak
% Fe		5.2		6.3		6.8	
Mo 3d_{5/2}	232.4 (1.2)	5.1	232.4 (1.1)	6.4	232.4 (1.0)	6.1	Mo⁶⁺
Mo 3d_{3/2}	235.6 (1.1)	3.4	235.6 (1.0)	4.3	235.6 (1.0)	4.0	
% Mo		8.5		10.7		10.1	
O 1s	530.9 (1.2)	31.5	530.7 (1.1)	40.8	530.6 (1.0)	38.8	O [Fe₂(MoO₄)₃]

Table 3

Parameters	Powder	As-dep. thin film
δ Isomeric shift (mm.s⁻¹)	0.41(1)	0.39(2)
Δ Quadrupole splitting (mm.s⁻¹)	0.18(2)	0.20(3)
Γ full width at half maximum (mm.s⁻¹)	0.30(2)	0.31(2)

Table 4

Figure captions

Figure 1 : XPS spectra of Fe 2p and Mo 6d for $\text{Fe}_2(\text{MoO}_4)_3$ powder (a, d), as-deposited (b, e) and annealed at 500 °C thin films (c, f).

Figure 2 : Room temperature ^{57}Fe Mössbauer spectra of a $\text{Fe}_2(\text{MoO}_4)_3$ thin film after 500 °C annealing and $\text{Fe}_2(\text{MoO}_4)_3$ powder.

Figure 3 : a) *In situ* XRD patterns of a $\text{Fe}_2(\text{MoO}_4)_3$ thin film measured during a staircase annealing between room temperature and 500 °C. b) Comparison of XRD patterns of the $\text{Fe}_2(\text{MoO}_4)_3$ powder and the thin film annealed at 500°C. A Rietveld refinement was achieved to precisely determine the cell parameters of the powder.

Figure 4: Raman spectra of $\text{Fe}_2(\text{MoO}_4)_3$ thin films, as-deposited and after annealing at 500°C (Raman spectrum of the $\text{Fe}_2(\text{MoO}_4)_3$ powder is shown as a reference).

Figure 5 : Surface and cross-section SEM images of $\text{Fe}_2(\text{MoO}_4)_3$ thin films; a,c) as-deposited and b,d) after annealing at 500°C.

Figure 6 : Voltage-composition profiles at C/20 a) and capacity retention b) for the $\text{Fe}_2(\text{MoO}_4)_3$ thin films as a function of the annealing temperature. c) Open circuit voltage (OCV) and dynamic voltage curves (C/20) for a thin film annealed at 500°C. d) Cyclic voltammetry for a $\text{Fe}_2(\text{MoO}_4)_3$ thin film annealed at 500°C.

Figure 7 : Evolution of the capacity and coulombic efficiency a) and b) voltage curves for $\text{Fe}_2(\text{MoO}_4)_3$ thin films annealed at 500°C as a function of the current rate.

Figure 1

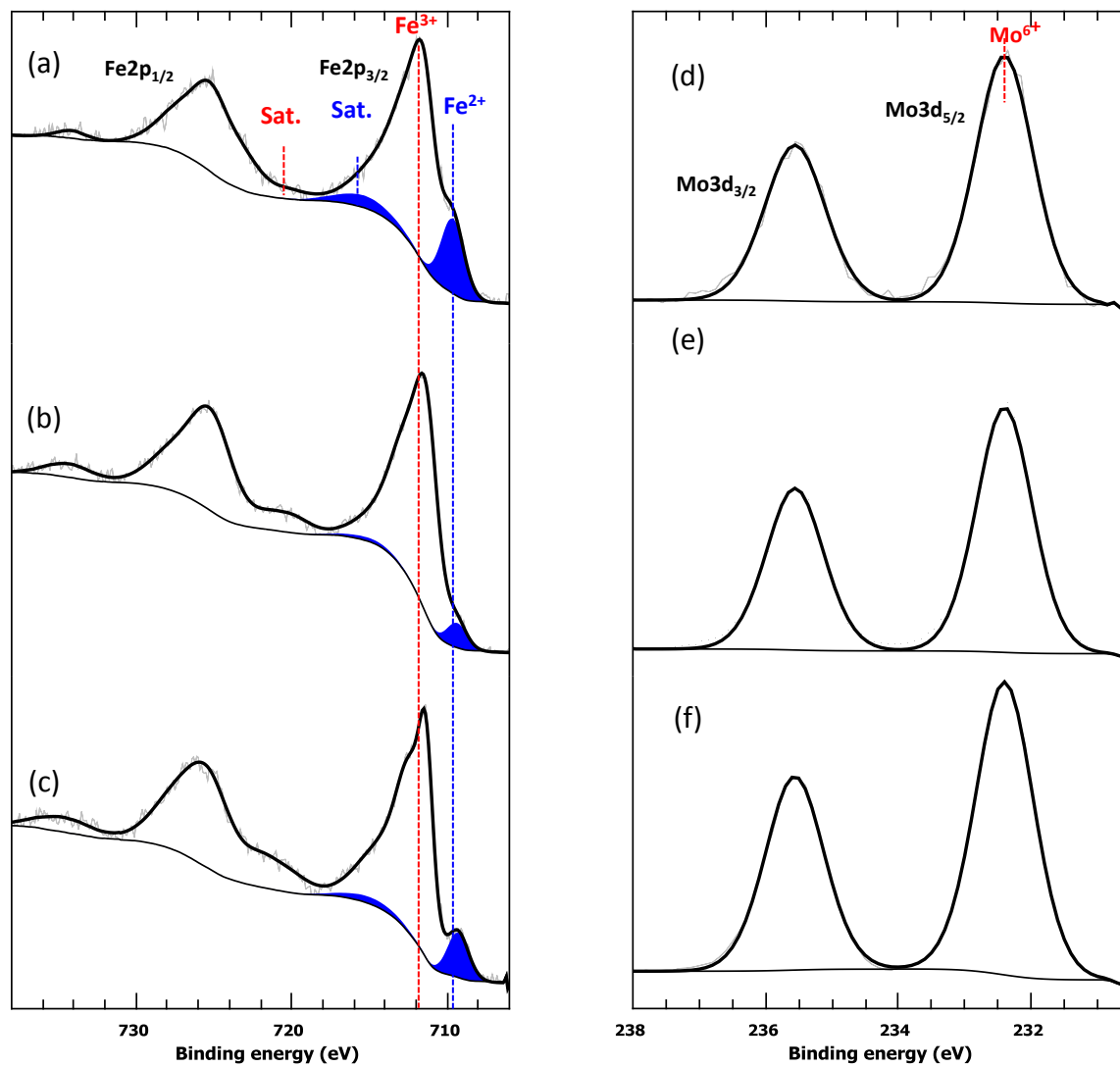


Figure 2

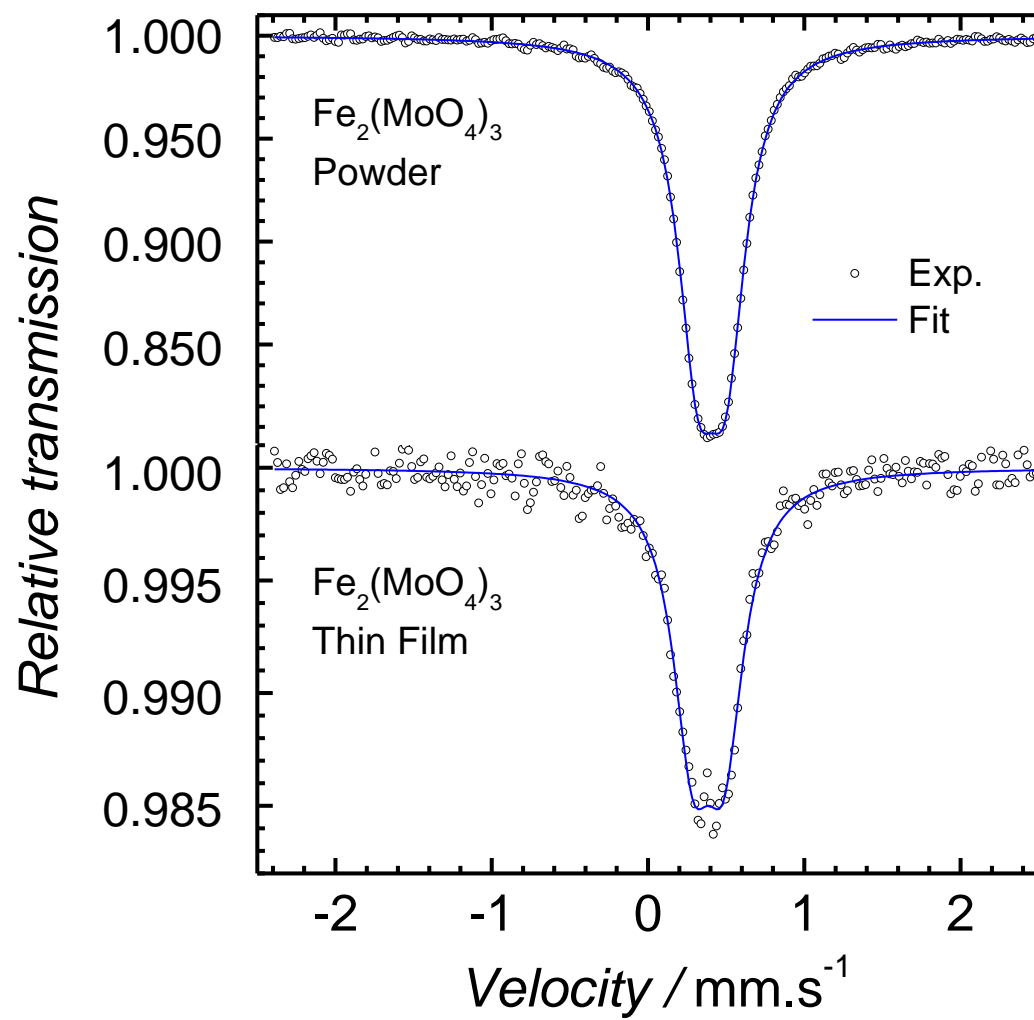


Figure 3

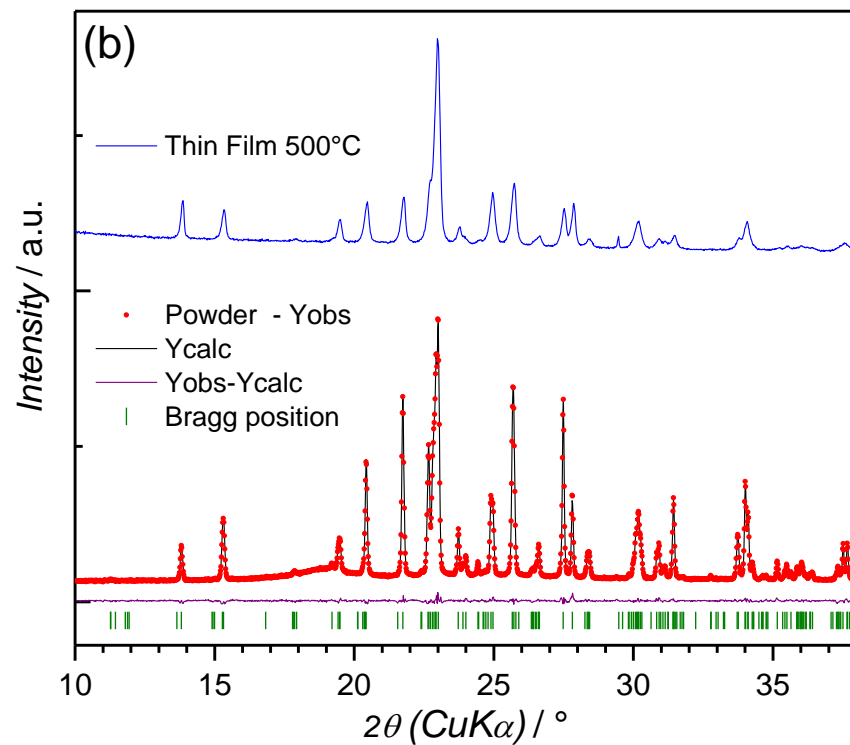
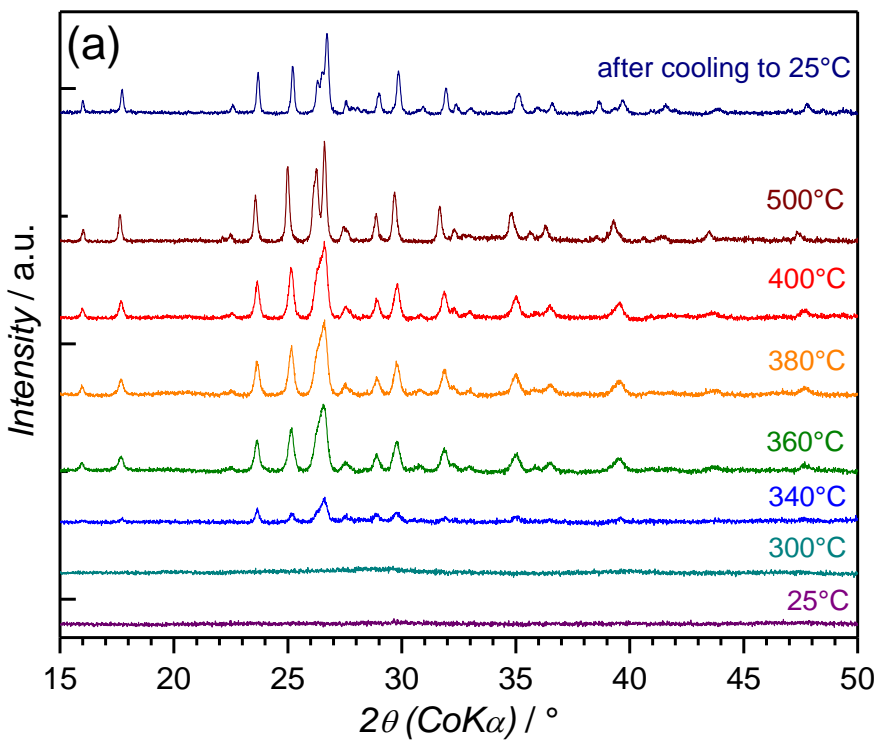


Figure 4

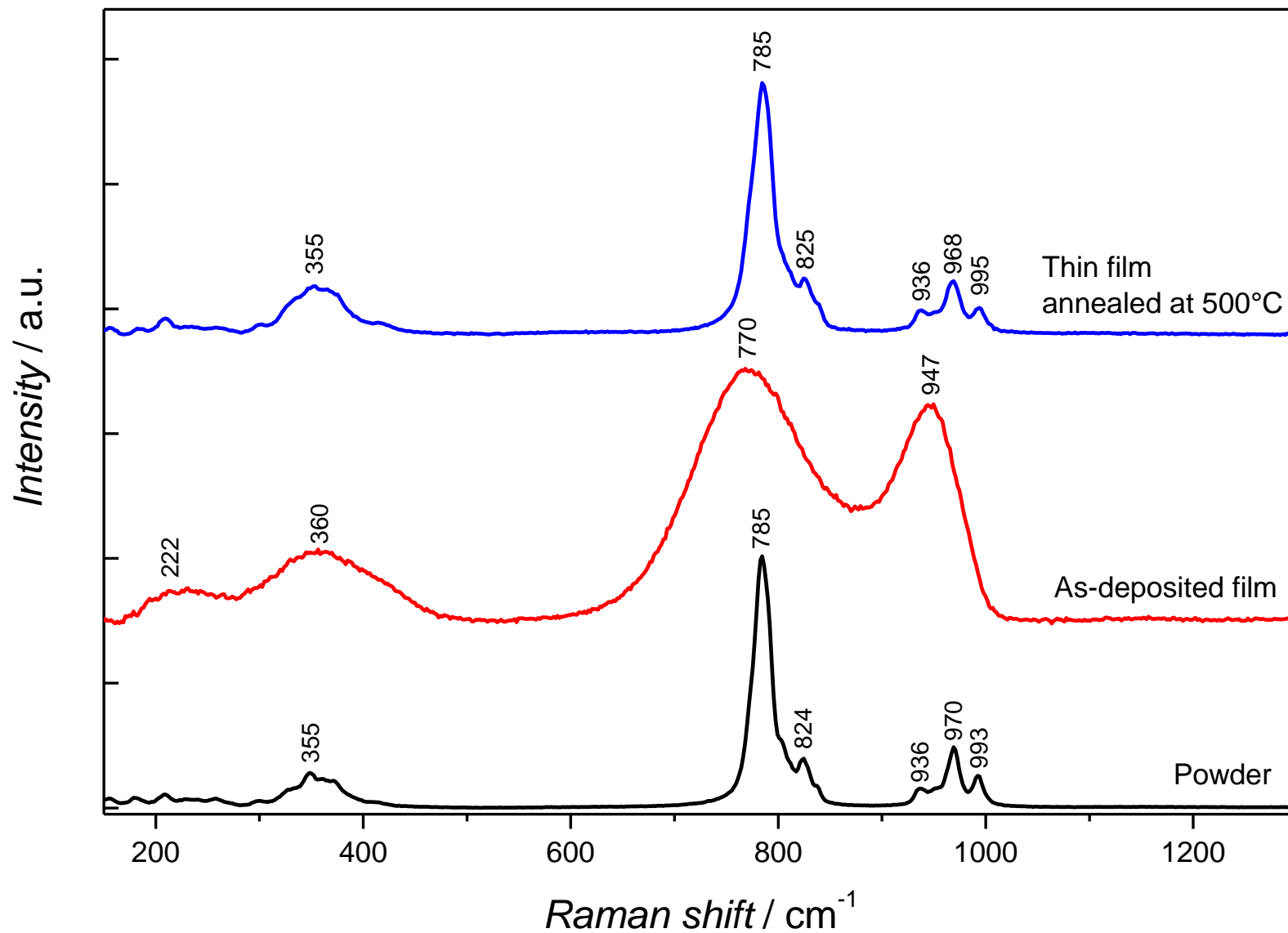


Figure 5

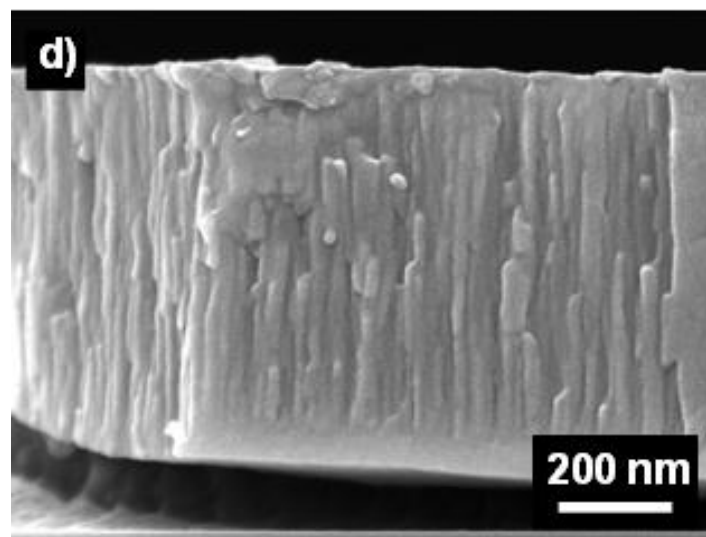
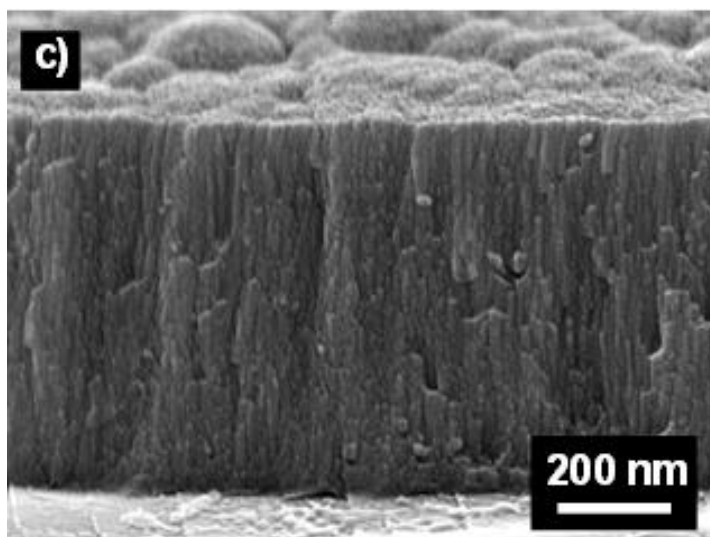
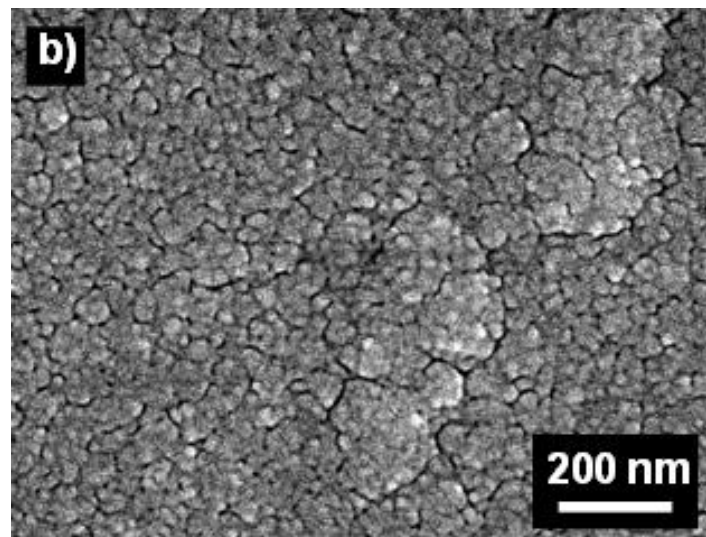
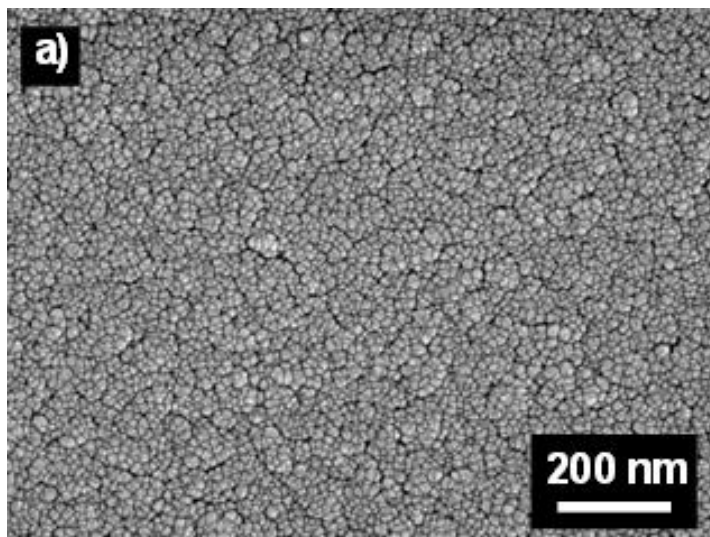


Figure 6

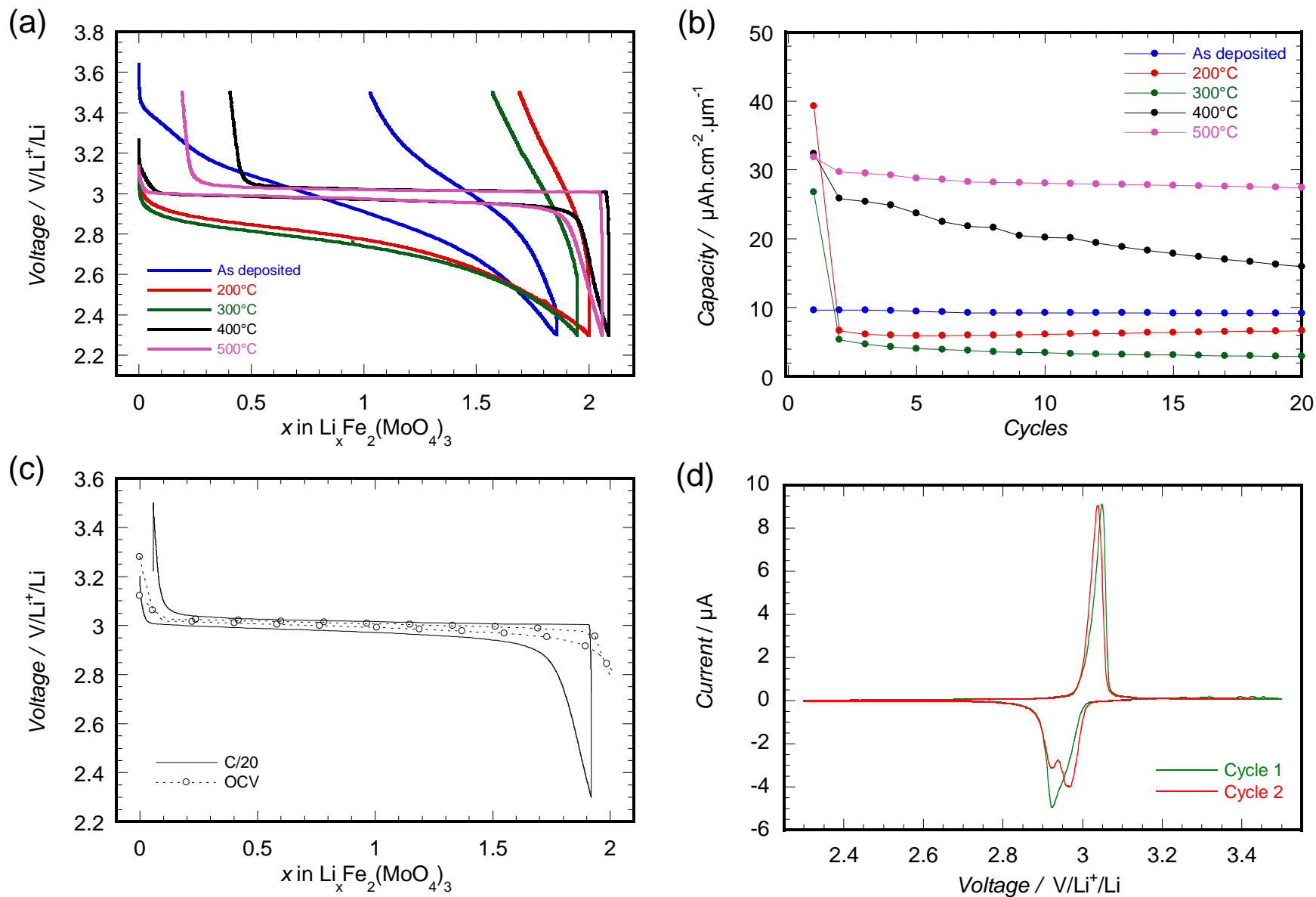


Figure 7

